

Faculty Position (Rank Open)
Nuclear, Plasma & Radiological Engineering
University of Illinois at Urbana-Champaign

The Department of Nuclear, Plasma, and Radiological Engineering at the University of Illinois at Urbana-Champaign is searching for two highly qualified individuals to join the faculty in tenured or tenure-track positions. Rank and salary will be commensurate with individual's qualifications.

Strong candidates with backgrounds in any of the areas related to nuclear and plasma applications will be considered. Applicants must hold a doctorate in a relevant area. The successful applicants must demonstrate the ability or the potential to develop a strong research and academic program, including teaching at both the undergraduate and graduate levels. Applicants are requested to supply an Oral proficiency in English must be demonstrated.

To apply for this position, please create a candidate profile at <http://jobs.illinois.edu> and upload a concise written synopsis of your research plans and educational goals along with detailed curriculum vitae, and names and contact information of a minimum of three professional references by June 18, 2010. All requested information must be submitted for your application to be considered. Interviews may take place during the application period, but a decision will not be made until after the closing date. The anticipated starting date is August 16, 2010 or negotiable.

For further information regarding application procedures, you may contact:

Department of Nuclear, Plasma, and Radiological Engineering

Telephone: (217) 333-2295

Fax: (217) 333-2906

Email: Nuclear@illinois.edu

The University of Illinois is an Affirmative Action /Equal Opportunity Employer. The administration, faculty and staff embrace diversity and are committed to attracting qualified candidates who also embrace and value diversity and inclusivity.